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Date: October 12, 2004

TO: Office of Initial Patent Examination's Filing Receipt Corrections

FACSIMILE NO.: (703) 746-9195

FROM: Thomas G. Eschweiler
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Re: U.S. Patent Application No. 10/814,570
Filing Date: March 31, 2004
Our Ref: MAIKP131US

Dear Sir or Madam:

Attached is an updated filing receipt for the above-identified application.

Please change the title on Page 2 from German to English as indicated below and on the filing receipt.

The English title is: Process for etching a substrate

Thank you.

PAGES TRANSMITTED INCLUDING THIS PAGE 3



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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE RECD	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/814,570	03/31/2004	1765	1030	MAIKP131US	4	8	1

29393
ESCHWEILER & ASSOCIATES, LLC
NATIONAL CITY BANK BUILDING
829 EUCLID AVE., SUITE 1210
CLEVELAND, OH 44114

CONFIRMATION NO. 6882

UPDATED FILING RECEIPT



OC000000013867845

Date Mailed: 09/23/2004

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections, facsimile number 703-746-9195. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

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Domestic Priority data as claimed by applicant

Foreign Applications

If Required, Foreign Filing License Granted: 06/11/2004

The number of your priority application, to be used for filing abroad under the Paris Convention is,
US10/814,570

Projected Publication Date: 10/06/2005

Non-Publication Request: No

Early Publication Request: No

Title Process for etching a substrate
~~Verfahren zur etzung eines substrates~~

Preliminary Class
438

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Title 37, Code of Federal Regulations, 5.11 & 5.15**

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